

AMENDMENTS TO THE SPECIFICATION

Please amend the paragraph beginning at page 21, line 14 as follows:

~~In the above Example 3, aA~~ resist pattern was formed by the same way as in the above Example 5 except that the dimension of the resist pattern was 120 nm L/S.

Please amend the paragraph beginning at page 23, line 16 as follows:

It was identified by $^1\text{H-NMR}$ and infrared absorption analysis that the yielded resin was the objective copolymer represented by the above general formula (11) (12) of monoisobornyl itaconate, α -(hydroxymethyl)acrylic acid methyl and α -(hydroxymethyl)acrylic acid ethyl. A polymerization ratio (l/m/n) was calculated to be 12/44/44 by measuring the monomer consumption rate using gas chromatography.